

FORM PTO-1449

U.S. DEPARTMENT OF COMMERCE
PATENT AND TRADEMARK OFFICEATTY. DOCKET NO.
MICRON.098CDV2APPLICATION NO.
10/615,524INFORMATION DISCLOSURE STATEMENT
BY APPLICANT

(USE SEVERAL SHEETS IF NECESSARY)

APPLICANT
Basceri et al.FILING DATE
July 3, 2003GROUP
2812 2823

U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPROPRIATE)
g/b	1	6,339,527	01/2002	Farooq et al.	361	3	x
g/b	2	6,277,436	08/2001	Stauf et al.	427	126.2	
g/b	3	5,822,175	10/1998	Azuma, Masamichi	361	321.5	
g/b	4	5,581,436	12/1996	Summerfelt et al.	361	321.1	
g/b	5	5,185,689	02/1993	Maniar, Papu D.	361	313	
g/b	6	6,660,535	12/2003	Basceri et al.	439	3	x

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO

EXAMINER INITIAL	OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)

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EXAMINER	William M. Basceri	DATE CONSIDERED	12 AUG 03
*EXAMINER: INITIAL IF CITATION CONSIDERED, WHETHER OR NOT CITATION IS IN CONFORMANCE WITH MPEP 609; DRAW LINE THROUGH CITATION IF NOT IN CONFORMANCE AND NOT CONSIDERED, INCLUDE COPY OF THIS FORM WITH NEXT COMMUNICATION TO APPLICANT.			

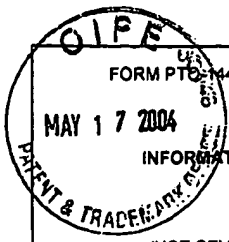
FORM PTO-1449	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTY. DOCKET NO. MICRON.098CDV2	APPLICATION NO. <u>Unknown</u> 18/615,521
INFORMATION DISCLOSURE STATEMENT BY APPLICANT (USE SEVERAL SHEETS IF NECESSARY)		APPLICANT Basceri et al.	
		FILING DATE Herewith 3 JUL 03	GROUP Unknown 2823

U.S. PATENT DOCUMENTS							
EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPROPRIATE)
QNB	1	5,335,138	8/2/94	Sandhu et al.	361	383	
QNB	2	5,406,445	4/11/95	Fujii et al.	361	385	
QNB	3	5,506,166	4/9/96	Sandhu et al.	438	396	
QNB	4	5,717,234	2/10/98	Si et al.	257	295	
QNB	5	5,781,404	7/14/98	Summerfelt et al.	361	321.5	
QNB	6	5,783,253	7/21/98	Roh	427	81	
QNB	7	5,889,299	3/30/99	Abe et al.	257	295	
QNB	8	5,973,911	10/26/99	Nishioka	361	313	
QNB	9	6,010,931	1/4/00	Sun et al.	438	240	
QNB	10	6,117,482	9/12/00	Kawahara et al.	427	10	
QNB	11	6,136,639	10/24/00	Seon	438	239	
QNB	12	6,319,764 B1	11/20/01	Basceri et al.	438	240	

EXAMINER INITIAL	OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)						
QNB	13	Hiromi Itoh et al., "Integration of BST Thin Film for Dram Fabrication."					
QNB	14	C. Basceri, "An Important Failure Mechanism in MOCVD (Ba Sr) TiO Thin Films: Resistance Degradation," Ferroelectric Thin Films IV, Materials Research Society, 1998, pp. 9-14					
QNB	15	Chung Ming Chu and Pan Lin, "Electrical Properties and Crystal Structure of a (Ba Sr) TiO3 Films Prepared at Low Temperatures on a LaNiO3 Electrode by Radio-Frequency Magnetron Sputtering," Appl. Phys. Lett., Vol. 70 (2), 13 January 1997, pp. 249-51					
	16						
	17						

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061903

EXAMINER	<u>William M. Brenner</u>	DATE CONSIDERED	<u>12 AUG 01</u>
*EXAMINER: INITIAL IF CITATION CONSIDERED. WHETHER OR NOT CITATION IS IN CONFORMANCE WITH MPEP 609: DRAW LINE THROUGH CITATION IF NOT. IN CONFORMANCE AND NOT CONSIDERED, INCLUDE COPY OF THIS FORM WITH NEXT COMMUNICATION TO APPLICANT.			

 <p>FORM PTO-1449</p> <p>U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE</p> <p>INFORMATION DISCLOSURE STATEMENT BY APPLICANT</p> <p>(USE SEVERAL SHEETS IF NECESSARY)</p>	ATTY. DOCKET NO. MICRON.098CDV2		APPLICATION NO. 10/815,524	
	APPLICANT Basceri et al.			
	FILING DATE July 3, 2003		GROUP 2823	

U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE (IF APPROPRIATE)
W/B	1.	6,285,051	09/04/01	Ueda et al.	257	296	

FOREIGN PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO

EXAMINER INITIAL	OTHER DOCUMENTS (INCLUDING AUTHOR, TITLE, DATE, PERTINENT PAGES, ETC.)

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051104

EXAMINER <i>William M. Brewster</i>	DATE CONSIDERED <i>12 AUG 01</i>
<p>*EXAMINER: INITIAL IF CITATION CONSIDERED, WHETHER OR NOT CITATION IS IN CONFORMANCE WITH MPEP 609; DRAW LINE THROUGH CITATION IF NOT IN CONFORMANCE AND NOT CONSIDERED, INCLUDE COPY OF THIS FORM WITH NEXT COMMUNICATION TO APPLICANT.</p>	